AMENDMENT

Claim Amendments

 (currently amended) A bi-directional ESD protection device, comprising at least-two DIAC devices, each DIAC device comprising

a first and a second p-well separated by formed in an n-well the p-wells and-n-well n-well-being formed in a p-substrate and isolated separated from the substrate by an n-isolation layer, wherein each of the first and second each p-well has a p-buried layer formed under it and each p-well includes a p+ region and an n+ region formed in it, the bi-directional ESD protection device further comprising an additional p-region comprises a p+ ring formed in a p-well surrounding each of the DIAC devices.

- 2. (previously presented) The device of claim 1, wherein the n+ regions in the two p-wells face each other to define a p+, n+, n+, p+ configuration.
- 3. (canceled)
- 4. (canceled)
- 5. (currently amended) The device of claim 1 3, wherein said p+ region is connected to ground.
- 6. (previously presented) The device of claim 1, wherein for each DIAC, the p+ and n+ regions in the first and second p-wells are connected together.
- 7. (previously presented) The device of claim 6, wherein the p+ and n+ regions in the first and second p-wells are connected together by means of a first metal layer.
- 8. (previously presented) The device of claim 6, wherein the n+ and p+ regions in the first p-well of the one DIAC are connected to an input pad.
- 9. (previously presented) The device of claim 7, wherein the n+ and p+ regions in the first p-well of the one DIAC are connected to an input pad.
- 10. (previously presented) The device of claim 9, wherein the n+ and p+ regions in the first p-well of the one DIAC are connected to the input pad by means of a second metal layer.

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11. (previously presented) The device of claim 8, wherein the n+ and p+ regions in the second p-well of the other DIAC are connected to a ground pad.

- 12. (previously presented) The device of claim 11, wherein the n+ and p+ regions in the second p-well of the other DIAC are connected to the ground pad by means of a second metal layer.
- 13. (previously presented) The device of claim 10, wherein the n+ and p+ regions in the second p-well of the other DIAC are connected to a ground pad.
- 14. (previously presented) The device of claim 13, wherein the n+ and p+ regions in the second p-well of the other DIAC are connected to the ground pad by means of the second metal layer.
- 15. (previously presented) The device of claim 11, wherein the n+ and p+ regions of the second p-well of the first DIAC are connected to the n+ and p+ regions in the first p-well of the other DIAC.
- 16. (previously presented) The device of claim 14, wherein the n+ and p+ regions of the second p-well of the first DIAC are connected to the n+ and p+ regions in the first p-well of the other DIAC by means of the second metal layer.